

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

PTO-1449 Information Disclosure Citation in an Application	Application No. 10/635,962	Applicant(s) Larry E. Hieb	
	Docket Number 065618.0109	Group Art Unit 3653	Filing Date August 7, 2003

U.S. PATENT DOCUMENTS

	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE
MPE A	3,556,345	01/19/71	Rowekamp	221	242	05/27/68
MPE B	3,674,175	07/04/72	Jaquish	221	92	11/12/70
MPE C	3,684,131	08/15/72	Kurimsky	221	242	04/22/70
MPE D	3,757,998	09/11/73	Millies et al.	221	242	12/08/71
MPE E	3,883,038	05/13/75	Bookout	221	67	11/12/73
MPE F	4,096,969	06/27/78	Ragusa	221	199	05/09/77
MPE G	4,168,784	09/25/79	Heler	221	125	10/05/77
MPE H	4,254,892	03/10/81	Lee	221	90	08/06/79
MPE I	4,757,915	07/19/88	Albright et al.	221	75	08/25/86
MPE J	4,846,387	07/11/89	Guigan et al.	221	81	07/01/87
MPE K	4,940,161	07/10/90	Hieb	221	67	06/28/88
MPE L	4,986,615	01/22/91	Hieb et al.	312	45	10/17/88
MPE M	5,127,546	07/07/92	Chen	221	242	08/08/91
MPE N	5,511,646	04/30/96	Maldanis et al.	194	217	06/03/93
MPE O	5,516,003	05/14/96	Hebert	221	130	11/28/94
MPE P	5,529,207	06/25/96	Oden et al.	221	67	01/25/95
MPE Q	5,799,823	09/01/98	Feltrin	221	298	10/28/96
MPE R	US 6,179,161 B1	01/30/01	Kovens et al.	221	131	11/13/98
MPE S	US 6,302,293 B1	10/16/01	Wittern, Jr., et al.	221	92	04/16/99
MPE T	US 6,513,887, B2	02/04/03	Paczkowski et al.	312	45	01/05/01

FOREIGN PATENT DOCUMENTS

	DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION
						YES NO
MPE U	PCT/US03/024897	08/07/03	PCT			

NON-PATENT DOCUMENTS

	DOCUMENT (Including Author, Title, Source, and Pertinent Pages)	DATE

EXAMINER	<i>Michael E. Bruck</i>	DATE CONSIDERED
		<i>12/9/05</i>

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